Docket No.: 5988-058-27

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

GROUP ART UNIT:

EXAMINER:

IN KE APPLICATION:

Eiji YONEDA, et

SERIAL NUMBER:

10/743.809

FILED:

December 24, 2003

FOR:

ONIUM SALT COMPOUND AND RADIATION-SENSITIVE RESIN COMPOSITION INFORMATION DISCLOSURE STATEMENT UNDER 37 C.F.R. 1.97

oi an an fan Datanta

Assistant Commissioner for Patents PO BOX 1450 ALEXANDRIA, VA 22313-1450

Sir:

Applicant(s) wish(es) to disclose the following information.

REFERENCES

Applicant(s) wish(es) to make of record the documents listed on the attached Form PTO-1449. Copies of the listed documents are attached, where required, as are either statements of relevancy or any readily available full or partial English translations of any non-English-language documents.

RELATED CASES

Attached is a list of Applicant's(s') pending applications and issued patents which may be related to the present application. Copies of the documents, where required, are attached along with Form PTO-1449.

CERTIFICATION

The undersigned certifies that

- each item of information contained in this Information Disclosure Statement was cited in a communication from a foreign or international patent office in a counterpart foreign or international application for the first time (to the knowledge of the undersigned, having made reasonable inquiry) not more than three months prior to the filing of this statement.
- no item of information contained in this Information Disclosure Statement was cited in a communication from a foreign or international patent office in a counterpart foreign or international application or, to the knowledge of the undersigned, having made reasonable inquiry, was known to any individual designated in 37 C.F.R. 1.56(c) more than three months prior to the filing of this statement.

BASIS FOR CONSIDERATION

This Information Disclosure Statement is filed:

- without fee and within three months of the filing date of the application.
- without fee and within three months of the date of entry of the U.S. national stage.
- without fee and before the mailing date of a first Office Action on the merits (to the knowledge of the undersigned).
- without fee and with the appropriate certification above.
- □ without fee and with a new CPA application.
- without fee and with a Request for Continued Examination.
- with fee and before the mailing date of any Final Office Action, Notice of Allowance or an action that otherwise closes prosecution (to the knowledge of the undersigned).
- with fee, appropriate certification above, and before payment of the Issue Fee.

DEPOSIT ACCOUNT

Please charge any additional fees for the papers being filed herewith and for which no check is enclosed herewith, or credit any overpayment to Deposit Account No. <u>50-1442</u>.

Respectfully submitted,

Steven B. Kelber Attorney of Record Registration No. 30,073

Christopher W. Raimund Registration No. 47,258

1200 Nineteenth Street, N.W. Washington, DC 20036-2412 Telephone No. (202) 861-3900 Facsimile No. (202) 223-2085



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF: Eiji YONEDA, et al.

ART UNIT:

SERIAL NO.: 10/743,809

EXAMINER:

FILING DATE: December 24, 2003

FOR:

ONIUM SALT COMPOUND AND RADIATION-SENSITIVE RESIN

COMPOSITION

STATEMENT OF RELEVANCY

ASSISTANT COMMISSIONER FOR PATENTS PO BOX 1450 ALEXANDRIA, VA 22313-1450

SIR:

This Statement of Relevancy is herewith submitted with the concurrently filed Information Disclosure Statement.

Japanese Patent Application Laid-open No. 59-45439 discloses a chemically-amplified radiation-sensitive composition containing a polymer of which the carboxyl group or phenolic hydroxyl group is protected with a t-butoxycarbonyl group and a photoacid generator. This composition utilizes the effect of the polymer to release the t-butoxycarbonyl group by the action of an acid generated by exposure to form an acidic functional group such as a carboxylic group or a phenolic hydroxyl group, which renders an exposed area on a resist film readily soluble in an alkaline developer.

Japanese Patent Application Laid-open No. 63-36332 discloses a sulfonium salt compound having a sulfonyl structure bonded with an aromatic ring which is useful as a photoinitiator due to a cation mechanism.

Consideration of the above cited references with all Information Disclosure Materials concurrently filed is respectfully requested.

Respectfully submitted,

PIPER RUDNICK LLP

Steven B. Kelber Registration No. 30,073 Attorney of Record

1200 Nineteenth Street, N.W. Washington, D.C. 20036-2412 Telephone No. (202) 861-3900 Facsimile No. (202) 223-2085

Christopher W. Raimund Registration No. 47,258

SHEET	1	OF	7
SUPET		OF	Τ.

Form PTO 1449 U.S. DEPARTMENT OF			DOCKET NO.	SERIAL NO.						
(Modified)		MMERCE TENT AND TRA	DEMARK	5988-058-27	10/743,809					
OFFICE			APPLICANT							
		2 JUI	5	Eiji YONEDA, et al.						
LIST OF REFERENCES CITED BY APPLICANT			FILING DATE	GROUP ART UNIT						
(Use Several Sheets if Necessary)			December 24, 2003							
U.S. PATENT DOCUMENTS										
EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB FILING DATE IF CLASS APPROPRIATE				
	AA									
	AB									
	AC									
	AD			· ·						
	AE			·						
	AF			-,						
	AG									
	AH									
	AI									
	AI									
FOREIGN PATENT DOCUMENTS										
		DOCUMENT NUMBER	DATE	COUNTRY	TRANSLA' YES			LATION NO		
	AK	JP59-45439	3/14/1984	JAPAN				х		
	AL	Љ63-36332	2/17/1988	JAPAN				х		
	AM				·					
OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, Etc.)										
	AN	Crivello, et al., "Complex Triarylsulfonium Salt Photoinitiators. II. The Preparation of Several New Complex Triarylsulfonium Salts and the Influence of Their Structure in Photoinitiated Cationic Polymerization", Journal of Polymer Science, Vol. 18, pp. 2697-2714, 1980.								
	AO	Hattori, et al., "Successive Beckmann Rearrangement-Alkylation Sequence by Organoaluminum Reagents. A Simple Route to <i>dl</i> -Pumiliotoxin C", J. Am. Chem. Soc., Vol. 103, pp. 7368-7370, 1981.								
	AP	Alemagna, et al., "S _N Ar Nucleophilic Substitutions of Cr(CO) ₃ -Complexed Aryl Halides with Thiolates under Phase-Transfer Conditions", J. Org. Chem., Vol. 48, pp. 605-607, 1983.								
	AQ	Migita, et al., "The Palladium Catalyzed Nucleophilic Substitution of Aryl Halides by Thiolate Anions", Bull. Chem. Soc. Jpn., Vol. 53, pp. 1385-1389, 1980.								
EXAMINER					DATE CONSIDERED					
				her or not citation is in conformance of this form with next communicatio			ne through	citation if		